

substance: boron compounds with group III elements**property: properties of γ -AlB₁₂**

Crystals of γ -AlB₁₂ are almost always obtained as syntactically intergrown crystals with α -AlB₁₂. When such intergrown crystals are pulverized, they are entirely transformed into the α -AlB₁₂ phase [99H1, 99H2]. Single phase crystals of the γ -AlB₁₂ structure type are obtainable by cooling an Al-B solution containing a small quantity of Mg [99H2]. Those crystals are not transformed to α -AlB₁₂ by pulverization.

preparation [77S, 77H, 60K], crystalline structure [77K, 77H, 60K, 75S, 77M1, 77M2]

Space group: P2₁2₁2₁ [87H].

Structure of γ -AlB₁₂ in Fig. 1 [83H, 87H].

Crystal chemistry of α -AlB₁₂ and γ -AlB₁₂ [99H3].

Preparation of α -AlB₁₂ and γ -AlB₁₂ [99H4].

lattice parameters

(in Å)

<i>a</i>	16.57	<i>T</i> = 300 K	single crystal, X-ray diffraction	85H,
<i>b</i>	17.51			87H,
<i>c</i>	10.14			94W
<i>V</i>	2942 Å ³			
<i>a</i>	16.66(10)	<i>T</i> = 300 K	single crystal, X-ray diffraction	87K
<i>b</i>	17.69(10)			
<i>c</i>	10.195(35)			

lattice parameters of Si-doped γ -AlB₁₂ (Al_{1.0}Si_{0.7}B_{15.6})

<i>a</i>	16.629	<i>T</i> = 300 K	X-ray diffraction	87G
<i>b</i>	17.551			
<i>c</i>	10.220			

occupancies of metal sites

(in %)

Al(1)	96.14	<i>T</i> = 300 K	X-ray diffraction	87H,
Al(2)	95.34			83H
Al(3)	94.64			
Al(4)	52.34			
Al(5)	74.74			
Al(6)	76.44			87H,
Al(7)	51.14			83H
Al(8)	44.44			
Al(9)	18.84			
Al(10)	19.04			
Al(11)	6.84			

B₂₀-(C₂) and B₂₀-(C₃) units in the γ -AlB₁₂ structure in Fig. 2 [83H].

energy gap of Si-doped γ -AlB₁₂ (Al_{1.0}Si_{0.7}B_{15.6})
(in eV)

E_g	0.36	$T = 300$ K	deep level	88W
	0.56		deep level	
	0.69		deep level	
	0.78		deep level	
	0.91		deep level	
	1.00		indirect allowed or non-direct	
	1.71		indirect allowed or non-direct	

Absorption edge of Si-doped γ -AlB₁₂ (Al_{1.0}Si_{0.7}B_{15.6}) in Fig. 3 [87G, 98W].

IR active phonon wavenumbers
(ν/c in cm⁻¹)

ν/c	1110	$T = 300$ K	obtained from the original data of the spectrum in Fig. 4	94W
	1054			
	1013			
	968			
	939			
	876			
	792			
	775			
	757			
	731			
	694			
	680			
	640			
	593			
	564			
	503			
	483			
	453			
	411			
	373			
	327			
	298			
	269			
	225			
	190			

Phonon absorption spectrum in Fig. 4 [94W].

activation energies

E_A	0.22 eV	$T = 100...375$ K	electrical conductivity	91P
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electrical conductivity

σ	$2.5 \cdot 10^{-4} \Omega^{-1} \text{cm}^{-1}$	$T = 293$ K		91P
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microhardness

(in GPa)

H_K	22.8(8)	load 1.96 N	91P
H_V	27.3(12)	load 1.96 N	87K
H	25.56	(+ Cr) hardness type not specified	88B
	24.45	(+ W) hardness type not specified	

microstrength

σ	1.6 GPa	(+ Cr)	88B
	1.46 GPa	(+ W)	

microbrittleness

γ	9.6	(+ Cr)	88B
	19.5	(+ W)	

fracture toughness

K_c	1.8(2) MN m ^{-3/2}		91P, 87K
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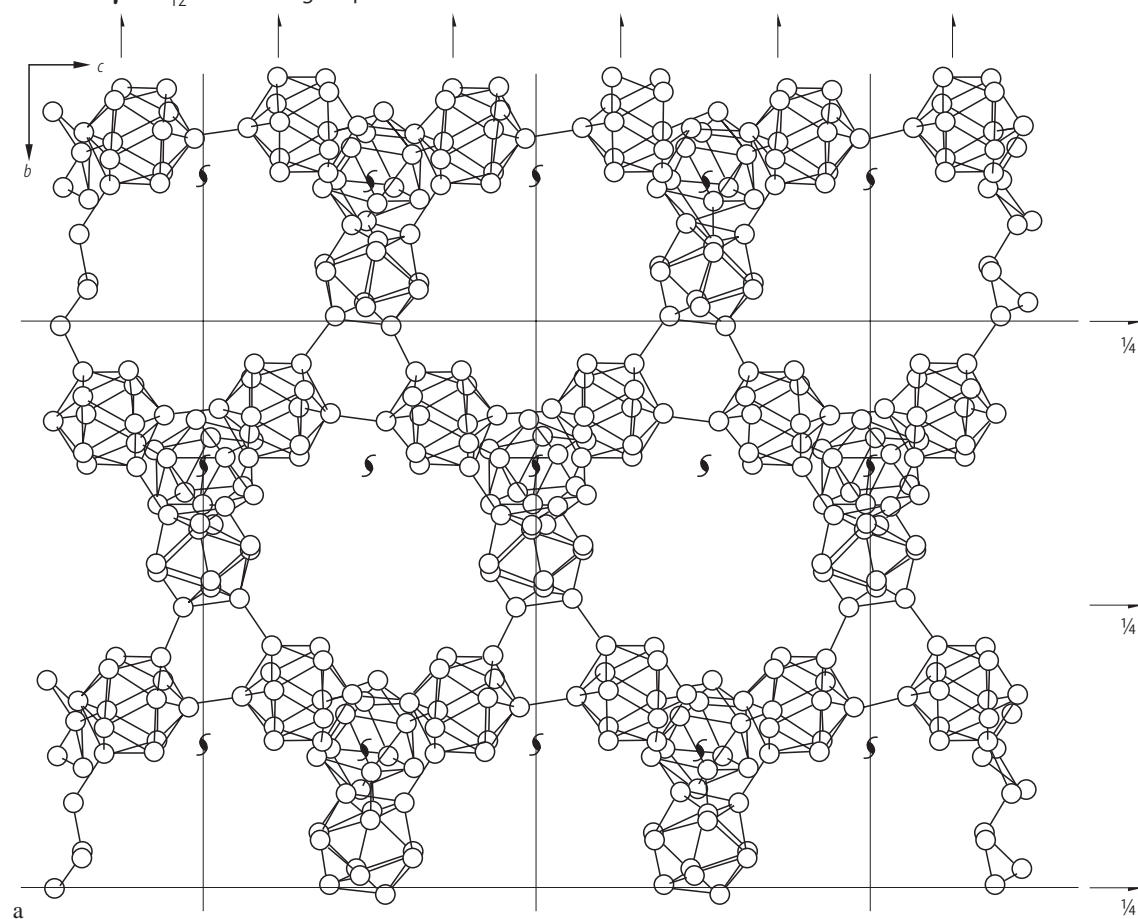
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Fig. 1.

Orthorhombic γ -AlB₁₂ structure group. Structure in a view parallel to [100]; (a) B₁₂ icosahedral arrangement, (b) features of the linkages between a B₂₀(C₂) unit and B₁₂ icosahedra, (c) arrangement of the B₄₈(T_d) subunit showing B₁₄₄(T_d) and truncated tetrahedral holes (the circles represent B₁₂ icosahedra) [83H]. For stereoscopic views of the B₂₀(C₂) and B₂₀(C₃) units and of the coordination of the metal sites to the boron framework see [83H].

orthorh. γ -AlB₁₂ structure group



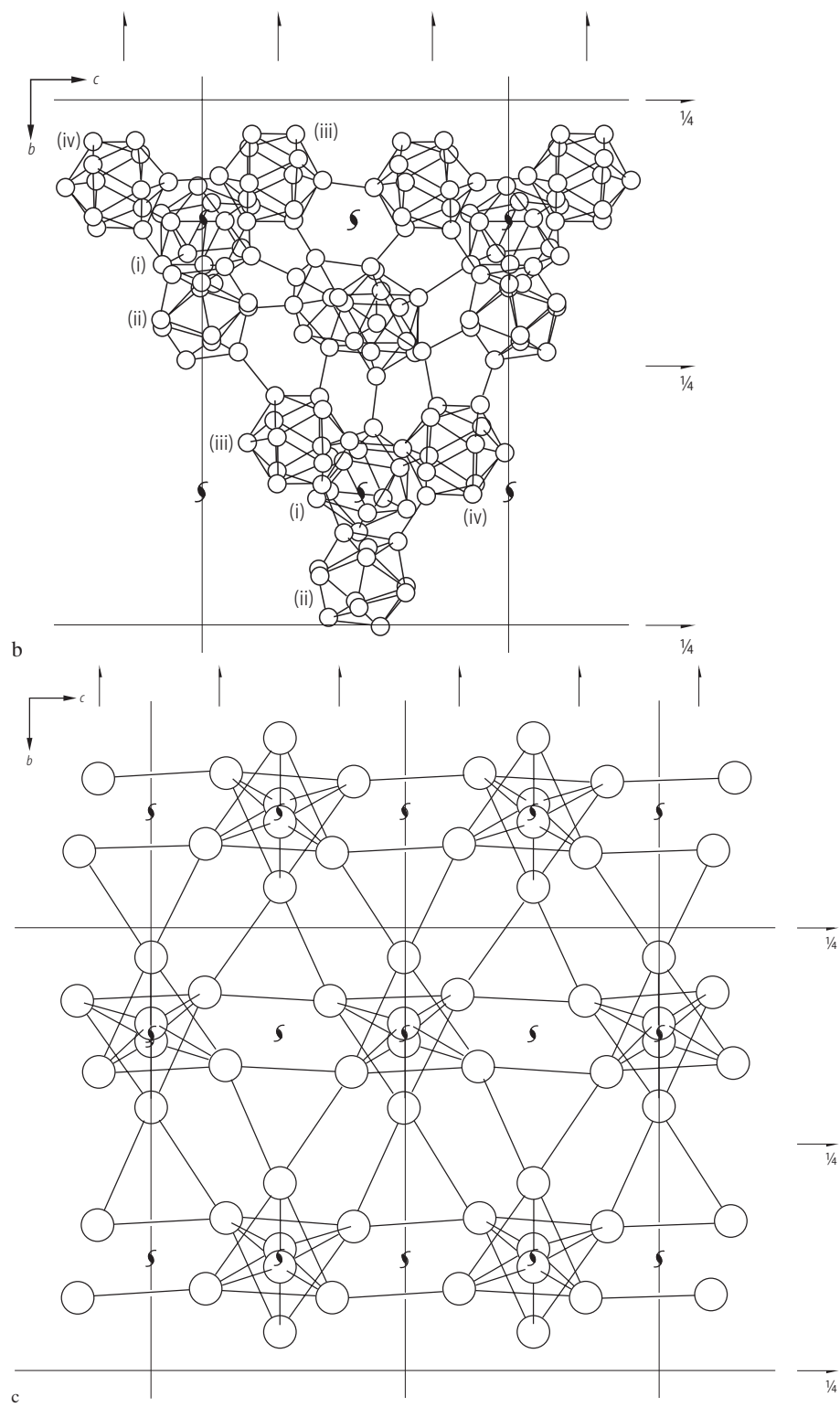


Fig. 2.

γ -AlB₁₂. Stereoscopic views of (a) B₂₀ (C₂) and (b) B₂₀ (C₃) units of the structure [83H].

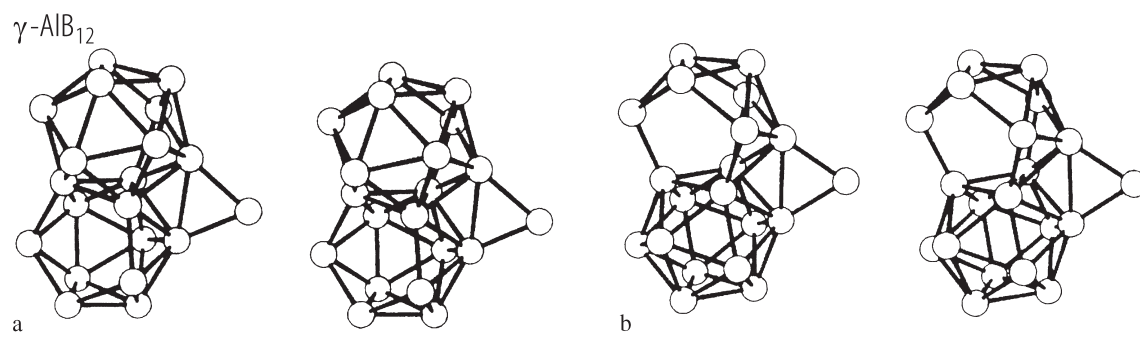


Fig. 3.

γ -AlB₁₂:Si. Absorption edge; absorption coefficient α vs. photon energy [98W] (at higher photon energies results of two different samples).

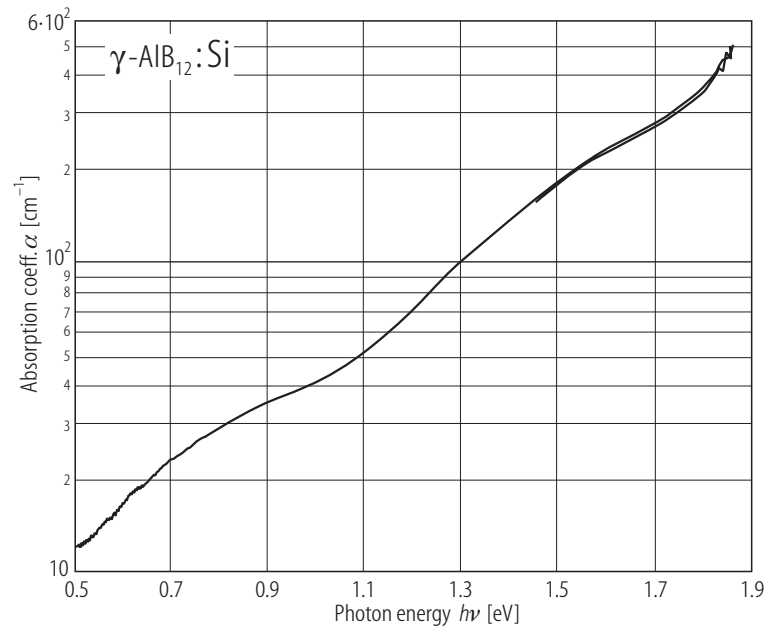


Fig. 4.

γ -AlB₁₂. IR phonon absorption spectrum. Absorption index vs. wavenumber [94W].

